

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Kim et al.

Serial No.: 10/683,937

Confirmation No.: 2191

Filed:

October 10, 2003

For: Method of Selective Deposition of

Heavily Doped Epitaxial SiGe

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

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Group Art Unit: 2812

Examiner:

Unassigned

CERTIFICATE OF MAILING 37 CFR 1.8

I hereby certify that this correspondence is being deposited on January 21, 2005 with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

January 21, 2005

Date

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

The Applicants, and the Attorney who signs below on the basis of the information supplied by the inventor and the information in his file, submit herewith patents, publications, or other information of which they are aware, which may be material to the examination of this application and in respect of which there may be a duty to disclose in accordance with 37 CFR § 1.56.

While the information submitted in this **Supplemental** Information Disclosure Statement may be material pursuant to 37 CFR § 1.56, it is not intended to constitute an admission that any patent, publication, or other information referred to therein is prior art for this invention unless specifically designated as such.

In accordance with 37 CFR § 1.97, this **Supplemental** Information Disclosure Statement is not to be construed as a representation that a search has been made or that no other possibly material information as defined under 37 CFR § 1.56(a) exists.

The patents and/or publications submitted herewith are set forth on the attached Form PTO-1449.

Applicants certify that all references submitted with this disclosure were first cited in a communication from a foreign patent office dated January 4, 2005, which communication is enclosed, not more than three months prior to the filing of this **Supplemental** Information Disclosure Statement.

If the sum of \$180.00 is due under 37 CFR § 1.17(p) pursuant to § 1.97, the Commissioner is hereby authorized to charge this fee, and any other fee necessary to make this submission timely, to the Deposit Account No. 20-0782/AMAT/8539/BTP.

Respectfully submitted,

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PTO/SB/08b(08-03)

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SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

Sheet of

Complete if Known				
Application Number	10/683,937			
Filing Date	October 10, 2003			
First Named Inventor	Kim et al.			
Art Unit	2812			
Examiner Name	Unassigned			
Attorney Docket Number	AMAT/8539/TSG/EPI/RKK			

NON PATENT LITERATURE DOCUMENTS				
Examiner Initials *			T 2	
	C1	Article by Uchino et al., entitled "A Raised Source/Drain Technology Using In-situ P-doped SiGe and B-doped Si for 0.1-µm CMOS ULSIs", IEDM, December 1997, Technical Digest, pgs. 479-482.		
	C2	Article by Sedgwick et al., entitled "Selective SiGe and heavily as doped Si deposited at low temperature by atmospheric pressure chemical vapor deposition", Journal of Vacuum Science & Technology, May/June 1993, No. 3, pgs. 1124-1128.		
	СЗ	Article by Kamins et al., entitled "Kinetics of Selective epitaxial deposition Si _{1-x} Ge _x ", American Institute of Physics, 1992/August, No. 6, pgs. 669-671		
	C4	Article by Menon et al., entitled "Loading effect in SiGe layers grown by dichlorosilane-and silane-based epitaxy", American Institute of Physics, 2001/November, Volume 90. No. 9, pgs. 4805-4809.		
	C5			
	C6			
	C7			
	C8			
	С9			
	C10			
	C11			
	C12			
	C13			

Examiner	Date	
Signature	Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance

and not considered. Include copy of this form with next communication to applicant:

Applicant's unique citation designation number (optional). Applicant is to place a check mark here if English language Translation is attached.

This collection of information is required by 37 CFR 1.98. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to take 120 minutes to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.